

Raymond T Tung

List of Publications by Year in Descending Order

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Version: 2024-04-20

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The third column is the impact factor (IF) of the journal, and the fourth column is the number of citations of the article.

19
papers

2,346
citations

10
h-index

20
g-index

20
ext. papers

2,587
ext. citations

6.6
avg. IF

6.03
L-index

#	Paper	IF	Citations
19	From NiSi ₂ experiments to density functional theory calculations: How the Schottky barrier mystery was solved. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2021 , 39, 020803	2.9	1
18	Quantitative explanation of the Schottky barrier height. <i>Physical Review B</i> , 2021 , 103,	3.3	6
17	Bulklike band-offset mystery solved through energy minimization: Lessons from perovskite oxide heterojunctions. <i>Physical Review B</i> , 2019 , 99,	3.3	5
16	Charge Density and Band Offsets at Heterovalent Semiconductor Interfaces. <i>Advanced Theory and Simulations</i> , 2018 , 1, 1700001	3.5	12
15	Band offset formation at semiconductor heterojunctions through density-based minimization of interface energy. <i>Physical Review B</i> , 2016 , 94,	3.3	13
14	The physics and chemistry of the Schottky barrier height. <i>Applied Physics Reviews</i> , 2014 , 1, 011304	17.3	595
13	Schottky barrier height systematics studied by partisan interlayer. <i>Thin Solid Films</i> , 2014 , 557, 254-257	2.2	8
12	Effect of metal interaction on the Schottky barrier height on adsorbate-terminated silicon surfaces. <i>Applied Surface Science</i> , 2013 , 284, 720-725	6.7	7
11	Modification of Schottky barrier height on Si (111) by Ga-termination. <i>Surface Science</i> , 2013 , 610, 48-52	1.8	6
10	Inhomogeneous ohmic contacts: Barrier height and contact area determination. <i>Applied Physics Letters</i> , 2012 , 101, 051604	3.4	9
9	Controlled modification of Schottky barrier height by partisan interlayer. <i>Solid State Communications</i> , 2011 , 151, 1641-1644	1.6	11
8	Bidirectional Control of Silicon Surface Potential by Means of Molecular Coverage. <i>Journal of Physical Chemistry C</i> , 2010 , 114, 18674-18678	3.8	9
7	Tuning the electrical properties of Si nanowire field-effect transistors by molecular engineering. <i>Small</i> , 2009 , 5, 2761-9	11	72
6	Controlling Au/n-GaAs junctions by partial molecular monolayers. <i>Physica Status Solidi (A) Applications and Materials Science</i> , 2006 , 203, 3438-3451	1.6	25
5	Controlling semiconductor/metal junction barriers by incomplete, nonideal molecular monolayers. <i>Journal of the American Chemical Society</i> , 2006 , 128, 6854-69	16.4	95
4	Combined UHV and Liquid Phase (CULP) Processing of Self-assembled Nanostructures. <i>Materials Research Society Symposia Proceedings</i> , 2005 , 879, 1		
3	Recent advances in Schottky barrier concepts. <i>Materials Science and Engineering Reports</i> , 2001 , 35, 1-138	30.9	915

- 2 Formation of an electric dipole at metal-semiconductor interfaces. *Physical Review B*, **2001**, 64, 33 253
- 1 Chemical bonding and fermi level pinning at metal-semiconductor interfaces. *Physical Review Letters*, **2000**, 84, 6078-81 74 301